

DOCKET NO: 284679US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
KUNIKAZU TAUCHI, ET AL. : EXAMINER: POURBOHLOUL, S. C.
SERIAL NO: 10/565,682 :
FILED: JUNE 28, 2006 : GROUP ART UNIT: 1796
FOR: SILICON-CONTAINING :
POLYMER, PROCESS FOR PRODUCING
THE SAME, HEAT-RESISTANT RESIN
COMPOSITION, AND HEAT-RESISTANT
FILM

RESPONSE TO THE REQUIREMENT FOR RESTRICTION

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Requirement for Restriction mailed August 17, 2009, Applicants elect, with traverse, Group I: Claims 1-2 drawn to an alkali-soluble silicon-containing polymer.

Applicants request that the Examiner expand the search to the non-elected claim of Group II, Claim 3, if the elected Group I claims are found allowable.

Remarks/Arguments begin on page 2 of this paper.